
Subject: Re: IDL versus AVS

Posted by [system](#) on Fri, 25 Nov 1994 14:48:18 GMT

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In article <3b35rtlNNiuj@rrzs3.uni-regensburg.de>, c9537@rrzs5
(Ulrich Krauss t4878) writes:

> can anyone point me to a comparison of IDL and AVS ?

> many thanks!

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I would be interested too, and also in comparisons of IDL
with PV-WAVE and Unigraph2000+.

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